Amendments to the Claims:

1. (Currently Amended) A device for measuring resistances associated with electrical contacts of a contact ring used in a semiconductor wafer electroplating process, said device comprising: a substrate which is configured such that the substrate is mountable in the contact ring; a conductive pattern on said substrate, said conductive pattern electrically contactable with the electrical contacts of the contact ring; and resistance measurement circuitry connected to said conductive pattern, said resistance measurement circuitry configured to not only send test signals to said conductive pattern, but also and configured to receive signals from the conductive pattern and measure the resistances associated with the electrical contacts of the contact ring.

- 2. (Original) A device as recited in claim 1, wherein said substrate is at least one of a silicon substrate and a metal substrate.
- 3. (Original) A device as recited in claim 1, wherein said resistance measurement circuitry is configured to communicate signals to an external device, said signals relating to resistances of the electrical contacts of the contact ring.
- 4. (Original) A device as recited in claim 1, said resistance measurement circuitry comprising a battery configured to power said resistance measurement circuitry.

Serial No. 10/723,701

Art Unit: 2829

(MON) 8. 8'05 14:45/ST. 14:43/NO. 4860347973 P

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5. (Original) A device as recited in claim 1, said resistance measurement circuitry

comprising input/output circuitry configured to initiate the sending of test signals to the

conductive pattern and communicate signals to an external device relating to resistances of the

electrical contacts of the contact ring.

6. (Original) A device as recited in claim 1, said resistance measurement circuitry

comprising multiplexer circuitry connected to said conductive pattern on the substrate and

configured to send the test signals to the conductive pattern on the substrate in a pre-determined

order.

7. (Original) A device as recited in claim 1, said resistance measurement circuitry

comprising multiplexer circuitry connected to said conductive pattern on the substrate, and

input/output circuitry connected to said multiplexer circuitry.

8. (Original) A device as recited in claim 7, wherein the multiplexer circuitry is

configured to send the test signals to the conductive pattern on the substrate in a pre-determined

order.

9. (Original) A device as recited in claim 7, wherein the input/output circuitry is

configured to provide a signal to the multiplexer circuitry, thereby causing the multiplexer

circuitry to start sending test signals to the conductive pattern on the substrate.

Serial No. 10/723,701

Art Unit: 2829

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(MON) 8. 8'05 14:45/ST. 14:43/NO. 4860347973 P 7

FROM TREXLER ETAL.

10. (Original) A device as recited in claim 1, said resistance measurement circuitry

comprising multiplexer circuitry connected to said conductive pattern on the substrate,

input/output circuitry connected to said multiplexer circuitry, and resistance determination

circuitry connected to said conductive pattern and to said input/output circuitry, said resistance

determination circuitry configured to determine resistances based on signals received from the

conductive pattern.

11. (Original) A device as recited in claim 9, wherein the input/output circuitry is

configured to communicate signals to an external device, said signals relating to resistances of

the electrical contacts of the contact ring.

12. (Currently Amended) A method of using a device to measure resistances

associated with electrical contacts of a contact ring used in a semiconductor wafer electroplating

process, the device comprising a substrate which is configured such that the substrate is

mountable in the contact ring, a conductive pattern on the substrate, and resistance measurement

circuitry connected to the conductive pattern, said method comprising mounting the substrate in

the contact ring thereby electrically contacting at least a portion of the conductive pattern on the

substrate with electrical contacts of the contact ring; having the device not only send test signals

to the conductive pattern, but also receive signals from the conductive pattern, and measure the

resistances associated with the electrical contacts of the contact ring.

Serial No. 10/723,701

Art Unit: 2829

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(MON) 8. 8'05 14:46/ST. 14:43/NO. 4860347973 P 8

FROM TREXLER ETAL.

13. (Original) A method as recited in claim 12, further comprising using the device to

communicate signals to an external device, said signals relating to resistances of the electrical

contacts of the contact ring.

14. (Original) A method as recited in claim 12, further comprising using a battery to

power the resistance measurement circuitry on the device.

15. (Original) A method as recited in claim 12, using input/output circuitry connected

to the conductive pattern on the substrate to initiate sending the test signals and to communicate

signals to an external device, said signals relating to resistances of the electrical contacts of the

contact ring.

16. (Original) A method as recited in claim 12, further comprising using multiplexer

circuitry connected to the conductive pattern on the substrate to send the test signals to the

conductive pattern on the substrate in a pre-determined order.

17. (Original) A method as recited in claim 12, further comprising using resistance

determination circuitry connected to said conductive pattern to determine resistances based on

signals received from the conductive pattern.

Serial No. 10/723,701

Art Unit: 2829

FROM TREXLER ETAL.

18. (Original) A method as recited in claim 12, further comprising removing the device from the contact ring, cleaning at least one of the electrical contacts of the contact ring, and using the device again to measure the resistances associated with the electrical contacts of the contact ring.

Serial No. 10/723,701

Art Unit: 2829